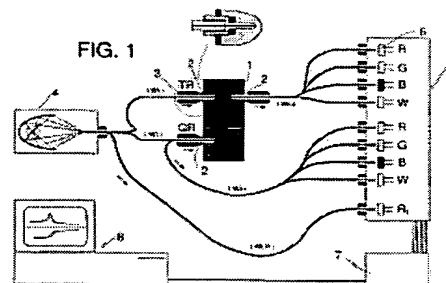


Photometrical measuring device**Patent number:** EP0472899**Publication date:** 1992-03-04**Inventor:** ETTMUELLER JUERGEN (DE); EUSTACHI WOLFGANG (DE); HAGENOW ANDREAS (DE); POLKE REINHARD DR (DE);
RAEDLE MATTHIAS DR (DE); SCHAEFER MICHAEL DR (DE)**Applicant:** BASF AG (DE)**Classification:****- international:** G01N15/14; G01N21/53; G01N21/85**- european:** G01N21/25C; G02B6/28B; G02B6/36**Application number:** EP19910112286 19910723**Priority number(s):** DE19904024420 19900801**Also published
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EP0472899 (B1)**Cited documents:**DE2231873
FR2453399
WO8809494[Report a data error here](#)**Abstract of EP0472899**

The measuring device is used to determine the light intensity reaching a detector from a light source as a function of a sample. For this purpose, a flow-type cell (1) for the sample is introduced into an optical waveguide connection (OWG) between a light source (4) and a light detector (5). The optical waveguide (OWG) or waveguides project directly into the cell via openings (2).

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